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Thin-Film Structures for Photovoltaics

Editors: Eric D. Jones, Juris Kalejs, Rommel Noufi and Bhushan Sopori

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Thin-Film Structures for Photovoltaics

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PREFACE

This volume contains written records of many of the papers presented at the symposium on "Thin-Film Structures for Photovoltaics," held December 2-5, as part of the 1997 MRS Fall Meeting in Boston, Massachusetts. The purpose of this symposium was to provide a forum for the presentation of recent results on all aspects of thin-film research for photovoltaic applications.

We wish to thank all authors and attendees of the symposium for their stimulating and interesting presentation, and for the resulting interactions, comments and questions. We gratefully acknowledge the National Renewable Energy Laboratory and the U.S. Department of Energy: EE/RE and OER/BES for their support of this symposium. Finally, we also wish to thank the meeting chairs and the MRS staff for assistance and encouragement.

E. Jones
J. Kalejs
R. Noufi
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